

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s)

Hans Wilfried Peter KOOPS

Serial No.

09/462,283

Filed

March 29, 2000

For

METHOD FOR PRODUCING ACTIVE OR PASS

COMPONENTS ON A POLYMER BASIS FOR

INTEGRATED OPTICAL DEVICES

Art Unit

:

:

Examiner

S. Ahmed

1765

Commissioner for Patents

P.O. Box 1450

Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA:22313-

Date: ( ) 114 5 2003

Linda M Shudy (Res No. 47 084)

## TRANSMITTAL OF AMENDMENT AND REQUEST TO EXTEND

SIR:

Please find an Amendment, in response to an Office Action dated February 5, 2003 (the three-month shortened statutory date of May 5, 2003 being extended by three months to August 5, 2003), transmitted herewith for filing in the above-identified patent application.

The Commissioner is authorized to charge the extension fee of \$930.00 to the Kenyon & Kenyon Deposit Account No. 11-0600. The Commissioner is also authorized, as appropriate and/or necessary, to charge any additional fees (including any other Rule 136(a) extension fees) or credit any overpayment to Deposit Account No. 11-0600. A duplicate copy of this transmittal letter is enclosed for that purpose.

Dated: 149.5, 2003

Respectfully submitted,

By: 1 Cloud A Richard L. Mayer

(Reg. No. 22,490)

KENYON & KENYON

One Broadway

New York, New York 10004

(212) 425-7200

**CUSTOMER NO. 26646** 

IC VE

[2345/108





## IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant(s)

Hans Wilfried Peter KOOPS

Serial No.

09/462,283

Filed

March 29, 2000

For

THE CHIVEL METHOD FOR PRODUCING ACTIVE OR PA

COMPONENTS ON A POLYMER BASIS FOR

INTEGRATED OPTICAL DEVICES

Art Unit

1765

Examiner

S. Ahmed

Commissioner of Patents

P.O. Box 1450

Alexandria, VA 22313-1450

I hereby certify that this correspondence is being deposited with the United States Postal Service as first class mail in an envelope addressed to: Commissioner for Patents, P.O. Box 1450, Alexandria, VA 22313

## **AMENDMENT**

SIR:

In response to the Office Action having mailing date February 5, 2003, please reconsider the above-identified application based on the following.

## **IN THE CLAIMS:**

Please amend claim 7 without prejudice as follows:

7. (Twice amended) A process for fabricating active and passive polymer-based components for use in integrated optics according to a principle based on one of a gas-phase diffusion and a liquid-phase diffusion, comprising the steps of:

depositing onto an optoelectronic component at least one patternable polymer resist layer that is highly sensitive and that effects an intense polymerization when exposed;

producing an etching mask by exposing defined regions of the at least one patternable polymer resist layer corresponding to a later component;

transferring a geometry of the etching mask through a high-grade anisotropic deep etching into unprotected regions of the at least one patternable polymer resist layer located 08/11/2003 MAHMED1 00000041 110600 09462283